

# MICRO-332(b) Manufacturing DLLs (printemps)

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Cursus	Sem.	Type
Microtechnics	BA6	Obl.

Language of English teaching Credits 2.5 Unauthorized Withdrawal Summer Session Semester Spring During the Exam semester Workload 90h Weeks 14 Hours 5 weekly 5 weekly TP Number of positions It is not allowed to withdraw

from this subject after the registration deadline.

#### **Summary**

The goal of this DLL is to introduce students to both the practical aspects of micro-fabrication of a fully functional device.

#### Content

#### This course is reserved for students registered in the bachelor of micro-engineering!

This DLL includes two parts. One related to clean-room fabrication process ('Micro332(a)') and a second one ('Micro332(b)'), that addresses system integration and packaging.

The overall goal is to go through a small process chain of a wearable, to fabricate it, to integrate it and finally, to test it.

#### **Keywords**

photoresist, photolithography, wet etching, sheet resistance, under-etching, mask alignment, sensor packaging, microassembly, system level integration and testing.

#### **Learning Outcomes**

By the end of the course, the student must be able to:

- · Conduct experiments on photolitography and etching
- Interpret experimental results
- Apply the guidelines related to the work in a cleanroom environment
- · Conduct assembly experiments
- Interpret obtained measurement data

## Transversal skills

- Write a scientific or technical report.
- Evaluate one's own performance in the team, receive and respond appropriately to feedback.
- Keep appropriate documentation for group meetings.

#### **Teaching methods**

• Combination of lectures, prerecorded videos, demonstration and lab sessions.



## **Expected student activities**

### Micro 332(a): (Fall)

- 1. Introduction to the clean room (1 session): Clean room environment, security aspects, process flow chart.
- 2. Basic micro-electronic and microsystem procedures (2 sessions)
- 3. Photolithography step with alignment, and wet or dry etching step. (in Lausanne campus)
- 4. Electrical characterization
- 5. Report and summary preparation for knowledge transfer to the 2nd part of the course

#### Micro 332(b): (Spring)

- 1. Design of a 3D package for a wearable sensor
- 2. Assembly of the sensor electronics on the board (in Neuchâtel campus)
- 3. Overall integration and functionality testing
- 4. Modelling
- 5. Report preparation

#### **Assessment methods**

Final grade is the ECTS weighted average (2 and 3) of both grades for Micro 332(a) and the Micro 332(b), respectively. Assessment method is based on the reports.

### Supervision

Office hours No
Assistants Yes
Forum Yes
Others Moodle